

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	202	precursor same organic same (treat or treating or treated or treatment) same pore	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 19:50
L2	7	(thin near film) same precursor same organic same (treat or treating or treated or treatment) same pore	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 19:51
L3	20	(thin near film) same precursor same organic same (treat or treating or treated or treatment) same (void or hole or pore)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 19:51
L4	15	(thin near film) same precursor same organic same (treat or treating or treated or treatment) same (void or hole or pore) same (method or process)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 19:51
L5	2	((thin near film) same precursor same organic same (treat or treating or treated or treatment) same (void or hole or pore) same (method or process)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 19:52
L6	8	(precursor same organic same (treat or treating or treated or treatment) same (void or hole or pore) same (method or process)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 19:53
L7	11	((thin near film) same organic same (treat or treating or treated or treatment) same (void or hole or pore) same (method or process)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/13 19:53